

LISTING OF THE CLAIMS

The listing of claims will replace all prior versions and listings of claims in the application.

Listing of Claims:

1. **(Original)** A vertical cavity surface emitting laser, comprising:
 - a substrate;
 - a first mirror stack over the substrate;
 - an active region having a plurality of quantum wells over the first mirror stack;
 - a tunnel junction over the active region, a p-layer of the tunnel junction including GaPSb or AlGaPSb; and
 - a second mirror stack over the tunnel junction.
2. **(Original)** A vertical cavity surface emitting laser according to claim 1, wherein an n-layer of the tunnel junction further includes a compound selected from the group consisting of InP, AlInAs, AlInGaAs, InGaAs and InGaAsP.
3. **(Original)** A vertical cavity surface emitting laser according to claim 1, further including an n-type spacer adjacent the active region, and wherein the first mirror stack is an n-type DBR.

4. **(Original)** A vertical cavity surface emitting laser according to claim 1, further including an p-type spacer adjacent the tunnel junction, and wherein the second mirror stack is an n-type DBR.

5. **(Original)** A vertical cavity surface emitting laser according to claim 1, further including:

an n-type bottom spacer adjacent the active region, and wherein the first mirror stack is an n-type DBR; and
an p-type top spacer adjacent the tunnel junction,
wherein the first and second mirror stacks are each an n-type DBR.

6. **(Original)** A vertical cavity surface emitting laser according to claim 1, wherein the p-layer is grown by MOCVD or MBE.

7. **(Original)** A vertical cavity surface emitting laser according to claim 6, wherein the MOCVD grows the p-layer of the tunnel junction using TMAI, TMGa, TMSb and PH₃ in a temperature range between about 400 °C and about 900 °C.

8. **(Original)** A vertical cavity surface emitting laser according to claim 6, wherein the MBE grows the p-layer of the tunnel junction at a condition where the Equivalent Beam Pressures of group V sources are in a range of about 1×10^{-7} to about 1×10^{-3} torr and the growth rates of group III sources are less than about 10 $\mu\text{m}/\text{hour}$.

9. **(Original)** A vertical cavity surface emitting laser according to claim 6, wherein the p-layer is doped with carbon with a concentration greater than about $2 \times 10^{18} \text{ cm}^{-3}$.

10. **(Original)** A vertical cavity surface emitting laser according to claim 1, wherein the active region includes one of InGaAs, InGaAsP and AlInGaAs.

11. **(Original)** A vertical cavity surface emitting laser according to claim 1, wherein the first and second mirror stacks are lower and upper mirror stacks, respectively.

12. **(Original)** A tunnel junction having a p-layer including GaPSb or AlGaPSb.

13. **(Original)** A tunnel junction according to claim 12, wherein the p-layer is doped with carbon with a concentration greater than about $2 \times 10^{18} \text{ cm}^{-3}$.

14. **(Original)** A tunnel junction according to claim 12, further including an n-doped layer of a compound in the group consisting of InP, AlInAs, InGaAs, AlInGaAs, and InGaAsP.

15. **(Original)** A tunnel junction according to claim 14, wherein the n-doped layer is doped with a concentration greater than about $2 \times 10^{18} \text{ cm}^{-3}$.

16. **(Original)** A tunnel junction according to claim 14, wherein the n-doped layer is less than about 100 nanometers thick.

17. **(Original)** A tunnel junction according to claim 14, wherein the n-doped layer is doped with a concentration greater than about $2 \times 10^{18} \text{ cm}^{-3}$ and the n-doped layer is less than about 100 nanometers thick.

18. **(Original)** A long wavelength VCSEL, comprising:

- an indium-based semiconductor substrate;
- a first mirror stack over the substrate;
- an active region having a plurality of quantum wells over the first mirror stack;
- a tunnel junction over the active region, wherein a p-layer of the tunnel junction includes GaPSb or AlGaPSb; and
- a second mirror stack over the tunnel junction.

19. **(Original)** A long wavelength VCSEL according to claim 18, wherein an n-layer of the tunnel junction further includes a compound selected from the group consisting of InP, AlInAs, InGaAs, AlInGaAs and InGaAsP.

20. **(Original)** A long wavelength VCSEL according to claim 18, further including an n-type spacer adjacent the active region, and wherein the first mirror stack is an n-type DBR.

21. **(Original)** A long wavelength VCSEL according to claim 18, further including an p-type spacer adjacent the tunnel junction, and wherein the second mirror stack is an n-type DBR.

22. **(Original)** A long wavelength VCSEL according to claim 18, further including: an n-type bottom spacer adjacent the active region, and wherein the first mirror stack is an n-type DBR;

and an p-type top spacer adjacent the tunnel junction, wherein the first and second mirror stacks are each an n-type DBR.